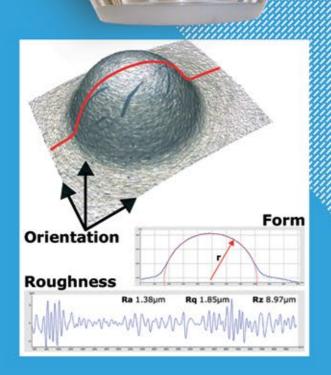
# alicona

manning



## **IF-SENSOR**R25

HOW TO ACHIEVE STABLE 3D MEASUREMENT IN PRODUCTION

### THE SYSTEM

### Optical 3D measurement sensor

IF-SensorR25 is a solid optical 3D measurement instrument for automated form and roughness measurement in production. The sensor is integrated into a production line and delivers high resolution, repeatable and traceable results when measuring surface characteristics in the  $\mu$ m or sub- $\mu$ m range. This resolution can hardly be achieved by conventional 2D solutions or tactile techniques.

### THE BENEFITS

### A measurement procedure from development to production

The robust technology of Focus-Variation delivers high resolution results with high repeatability in research and production. Therefore IF-SensorR25 is a platform that enables the use of the same measurement process both in-line and in the lab. Standardized interfaces (QDAS) support an easy and quick integration into production allowing comparable in-line and lab measurements.

### THE APPLICATION

### Measurement of surface quality and finest form tolerances

IF-SensorR25 is a measurement system for quality assurance in serial production. It is suitable for numerous materials including composite materials. The modular design allows arbitrary extensions of hard- and software for new and/or complex measurement tasks. In the field of EDM, the sensor can be implemented directly in a Makino machining center to perform in-machine measurement. This "closed loop manufacturing" production concept enables 3D measurement of components directly in the machine, enabling up to a fourfold increase in machining accuracy.

#### **GENERAL SPECIFICATIONS**

| non-contact, optical, three-dimensional, based |
|--|
| 25 mm (mot.)                                   |
| white LED high-power ring light, 24 segments   |
| coaxial laser beam                             |
| 126 mm x 153 mm x 202 mm, ControlServerH       |
| 4 kg   |
| 12 Core, 32 GB, 24" HD LED Monitor             |
| surface texture: surface topography Ra above   |
|  |

#### **OBJECTIVE SPECIFIC FEATURES**

| Objective magnification (*)                |                       | 10x                                   | 20x    | 50x         | 2xSX      | 5xSX    | 10xSX  | 20xSX  | 50xSX       |
|--|-----------------------|---------------------------------------|--------|-------------|-----------|---------|--------|--------|-------------|
| Working distance                           | mm                    | 17.5                                  | 13     | 10.1        | 34        | 34      | 33.5   | 20     | 13          |
| Lateral measurement range (X,Y)<br>(X x Y) | mm<br>mm <sup>2</sup> | 2<br>4                                | 1<br>1 | 0.4<br>0.16 | 10<br>100 | 4<br>16 | 2<br>4 | 1<br>1 | 0.4<br>0.16 |
| Measurement point distance                 | μm                    | 1                                     | 0.5    | 0.2         | 5         | 2       | 1      | 0.5    | 0.2         |
| Finest lateral topographic resolution      | μm                    | 2                                     | 1      | 0.64        | 10        | 4       | 2      | 1      | 0.64        |
| Measurement noise                          | nm                    | 40                                    | 20     | 10          | 1240      | 180     | 45     | 25     | 15          |
| Vertical resolution                        | nm                    | 100                                   | 50     | 20          | 3500      | 510     | 130    | 70     | 45          |
| Vertical measurement range                 | mm                    | 16                                    | 12     | 9           | 25        | 25      | 25     | 19     | 12          |
| Measurement speed                          |                       | ≤ 1.7 million measurement points/sec. |        |             |           |         |        |        |             |

(\*) Objectives with longer working distance available upon request

#### **RESOLUTION AND APPLICATION LIMITS**

| Objective magnification        |    | 10x  | 20x   | 50x  | 2xSX | 5xSX | 10xSX | 20xSX | 50xSX |
|--------------------------------|----|------|-------|------|------|------|-------|-------|-------|
| Min. measurable height         | nm | 100  | 50    | 20   | 3500 | 510  | 130   | 70    | 45    |
| Max. measurable height         | mm | 16   | 12    | 9    | 25   | 25   | 25    | 19    | 12    |
| Height step accuracy (1mm)     | %  | 0.5  |       |      |      |      |       |       |       |
| Min. measurable roughness (Ra) | μm | 0.3  | 0.15  | 0.08 | n.a. | n.a. | 0.45  | 0.25  | 0.15  |
| Min. measurable roughness (Sa) | μm | 0.15 | 0.075 | 0.05 | n.a. | n.a. | 0.25  | 0.1   | 0.08  |
| Min. measurable radius         | μm | 5    | 3     | 2    | 20   | 10   | 5     | 3     | 2     |
| Min. measurable wedge angle    | 0  | 20   |       |      |      |      |       |       |       |
| Max. measurable slope angle    | 0  | 87   |       |      |      |      |       |       |       |

### ACCURACY

| Flatness deviation                          | 2 mm x 2 mm with 10x objective   | U = 0.1 µm   |
|---|--|--|
| Max. deviation of a height step measurement | height step 1000 µm<br>height step 100 µm<br>height step 10 µm<br>height step 1 µm | $ \begin{array}{l} E_{\text{Uni: St: ODS, MPE}} = 1 \ \mu\text{m}, \ \sigma = 0.1 \ \mu\text{m} \\ E_{\text{Uni: St: ODS, MPE}} = 0.4 \ \mu\text{m}, \ \sigma = 0.05 \ \mu\text{m} \\ E_{\text{Uni: St: ODS, MPE}} = 0.3 \ \mu\text{m}, \ \sigma = 0.025 \ \mu\text{m} \\ E_{\text{Uni: St: ODS, MPE}} = 0.15 \ \mu\text{m}, \ \sigma = 0.01 \ \mu\text{m} \end{array} $ |
| Profile roughness                           | Ra = 0.5 µm  | U = 0.04 μm, σ = 0.002 μm  |
| Area roughness                              | Sa = 0.5 µm  | U = 0.03 μm, σ = 0.002 μm  |
| Distance measurement                        | XY up to 2 mm  | E <sub>Bi: Tr: ODS, MPE</sub> = 0.8 μm   |
| Wedge angle                                 | β = 70 ° - 110 °   | U = 0.15 ° , σ = 0.02 °  |
| Edge radius                                 | R = 5 μm - 20 μm<br>R > 20 μm  | U = 1.5 µm, σ = 0.15 µm<br>U = 2 µm, σ = 0.3 µm  |

E<sub>Uni: St: ODS, MPE</sub> & E<sub>Bi: Tr: ODS, MPE</sub> conform to ISO 10360-8

### SOFTWARE

| Automation | integrated scripting language; LabVIEW frame<br>Alicona Inspect Professional (enables GD&T r |
|------------|--|
|------------|--|



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d on Focus-Variation

HP: 190 mm x 500 mm x 450 mm

0.009  $\mu$ m with  $\lambda_{c}$  2  $\mu$ m; depending on surface structure

ework; .NET remoting interface; measurement)